PATENT APPLICATION

THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Isao ITO et al.

Group Art Unit: 1755

Application No.: 10/539,589

Docket No.: 124196

Filed: February 17, 2006

For: MANUFACTURING METHOD OF CERAMIC STRUCTURE

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records. A Supplemental Application Data Sheet is attached.

Respectfully submitted

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JAO:LMS/crh

Date: May 15, 2006

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/539,589	02/17/2006	1755	1030	124196	2	16	1

25944 **OLIFF & BERRIDGE, PLC** P.O. BOX 19928 **ALEXANDRIA, VA 22320**



CONFIRMATION NO. 4793



Date Mailed: 03/27/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16378 12/19/2003

Foreign Applications

S 8 1 2

JAPAN 2002-376960 12/26/2002

Projected Publication Date: 07/06/2006

Non-Publication Request: No

Early Publication Request: No

PLEASE SEE PAGE 2 *
FOR ADDITIONAL CORRECTIONS

Manufacturing seramic structure— Manufacturing METHOD OF CERAMIC STRUCTURE Preliminary Class

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